

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 7,056,809 B2  
APPLICATION NO. : 10/695938  
DATED : June 6, 2006  
INVENTOR(S) : Rayssac

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 10:

Line 28 (claim 6, line 2), after "the plasma are Si and SF<sub>6</sub>, SiC and SF<sub>6</sub>/O<sub>2</sub>," insert -- SiO<sub>2</sub> --.

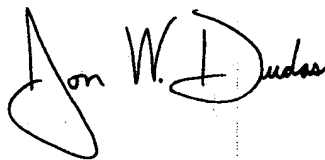
Line 58 (claim 14, line 5), after "clusters that is directed to" delete "is directed to".

Column 11:

Line 9 (claim 17, line 4), after "controlled number of" delete "ion sin" and insert -- ions in --.

Signed and Sealed this

Twenty-seventh Day of March, 2007

A handwritten signature in black ink, appearing to read "Jon W. Dudas". The signature is stylized with a large, looped initial "J" and a cursive "Dudas".

JON W. DUDAS  
*Director of the United States Patent and Trademark Office*